Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L2	1	"5520744".PN.	USPAT; USOCR	OR	OFF	2005/09/29 13:39
L3	764	(wafer or substrate) and (HF or hydrofluoric) and "hydrogen peroxide" and (peripheral or circumference) and (copper or Cu)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/29 14:25
L4	408	(wafer or substrate) same (HF or hydrofluoric) and "hydrogen peroxide" same (copper or Cu)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/29 14:20
L7	140	((wafer or substrate) and (HF or hydrofluoric) and "hydrogen peroxide" and ((copper or Cu) adj remov$4))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/29 14:39
L11	1796	(wafer or substrate) and (HF or hydrofluoric) and ("hydrogen peroxide" or "H.sub.2O.sub.2") and (copper or Cu or cobalt) and (chamber or reactor)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/29 14:42
L12	902	(wafer or substrate) and (HF or hydrofluoric) and ("hydrogen peroxide" or "H.sub.2O.sub.2") and (peripheral or edge or circumference) and (copper or Cu or cobalt) and (chamber or reactor)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/29 14:58
L15	366	(wafer or substrate) and (HF or hydrofluoric) and ("hydrogen peroxide" or "H.sub.2O.sub.2") and (peripheral or edge or circumference) and (cobalt) and (chamber or reactor)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/29 14:59
L16	3	aegerter-brian-k.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/29 15:31

L17	15	dundas-curt-t.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/29 15:33
L18	7	ritzdorf-tom-l.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/29 15:33
L19	12	jolley-michael.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/29 15:33